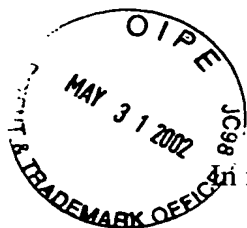


PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



In re the Application of

Masaya ISHIDA et al.

Application No.: 10/026,653

Filed: December 27, 2001

Docket No.: 111594

For: SYSTEM AND METHODS FOR MANUFACTURING A MOLECULAR FILM  
PATTERN (As Amended)

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SUPPLEMENTAL PRELIMINARY AMENDMENT

Director of the U.S. Patent and Trademark Office  
Washington, D. C. 20231

Sir:

Further to the Preliminary Amendment filed on April 26, 2002, and prior to initial examination, please amend the above-identified application as follows:

IN THE TITLE:

Please replace the title as follows:

SYSTEM AND METHODS FOR MANUFACTURING A MOLECULAR FILM PATTERN

IN THE ABSTRACT:

Please replace the Abstract filed with the substitute Abstract attached hereto.

IN THE SPECIFICATION:

Please replace the specification filed with the substitute specification attached hereto.

IN THE CLAIMS:

Please replace claims 1-23 as follows:

1. (Amended) A method for manufacturing a molecular film pattern,  
comprising:

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